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**Understanding Water-Oxide
Interfaces to Harness New
Processes and Technologies**

Journal of MATERIALS RESEARCH

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UNDERSTANDING WATER-OXIDE INTERFACES TO HARNESS NEW PROCESSES AND TECHNOLOGIES

- 357–358 **Introduction** Kevin M. Rosso, Oliver Diwald,
Ricardo H.R. Castro

EDITORIAL

- 359 **Editorial** Gary L. Messing

INVITED REVIEW

- 360–378 **Interaction of water with oxide thin film model systems** Martin Sterrer, Niklas Nilius,
Shamil Shaikhutdinov,
Markus Heyde, Thomas Schmidt,
Hans-Joachim Freund

INVITED ARTICLE

- 379–393 **Dissociation of water on atomically-defined cobalt oxide nanoislands on Pt(111) and its effect on the adsorption of CO** Tobias Wähler, Chantal Hohner,
Zhaozong Sun, Ralf Schuster,
Jonathan Rodríguez-Fernández,
Jeppe Vang Lauritsen, Jörg Libuda

INVITED REVIEW

- 394–407 **Thermochemistry of volatile metal hydroxides and oxyhydroxides at elevated temperatures** Dwight L. Myers, Nathan S. Jacobson,
Charles W. Bauschlicher, Jr.,
Elizabeth J. Opila

INVITED ARTICLE

- 408–415 **Water dissociation on the low-coordinated sites of MgO nanopowders** Fabio Finocchi, Francia Haque,
Stéphane Chenot, Jacques Jupille,
Slavica Stankic

INVITED REVIEWS

- 416–427 **Review of surface water interactions with metal oxide nanoparticles** Jason J. Calvin, Peter F. Rosen,
Nancy L. Ross, Alexandra Navrotsky,
Brian F. Woodfield
- 428–441 **Thin water films covering oxide nanomaterials: Stability issues and influences on materials processing** Gilles R. Bourret, Oliver Diwald

INVITED ARTICLES

- 442–455 **Systematic dependence of kinetic and thermodynamic barriers to homogeneous silica nucleation on NaCl and amino acids** Patricia M. Dove, Nizhou Han,
Adam F. Wallace
- 456–464 **Lateral water structure connects metal oxide nanoparticle faces** Piotr Zarzycki, Christopher A. Colla,
Benjamin Gilbert, Kevin M. Rosso

465–473 **An unexpected phase transformation of ceria nanoparticles in aqueous media**

Satyanarayana V.N.T. Kuchibhatla,
Ajay S. Karakoti, Andreas E. Vasdekis,
Charles F. Windisch, Jr., Sudipta Seal,
Suntharampillai Thevuthasan,
Donald R. Baer

474–480 **Grain growth of titania to submillimeter sizes using water vapor-assisted sintering**

Takahiro Kozawa,
Kazumichi Yanagisawa